



Maximizing CCC and the March to an Unburnable Probe



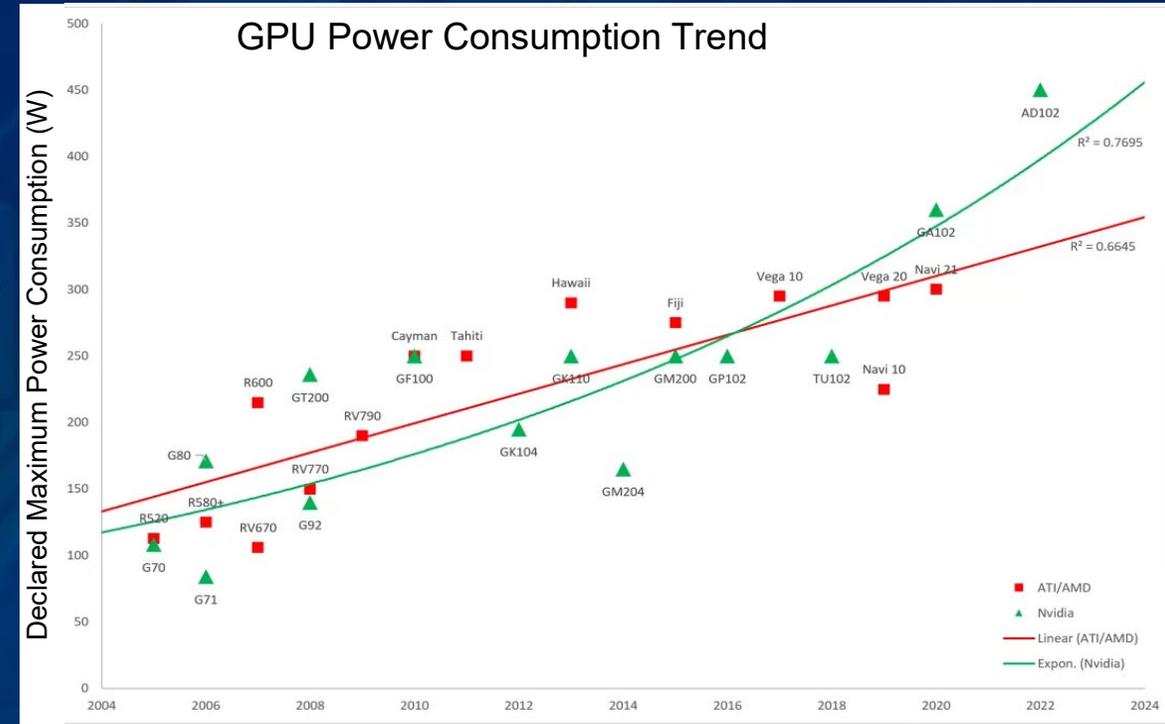
Dr. Hadi Najjar
FormFactor

Agenda

- **Why Does CCC matter?**
- **Hybrid Probe Review**
- **Next Generation Probe Review**
- **Metallized Guide Plate Review**
- **Maximized CCC Conclusion**

Industry Trends

- **High Performance Compute and GPU applications are marching to 1kW devices (1,000A at 1V)**
 - Shipping 400A devices today (400W at 1V)
 - Newest HPC devices have >50 Billion Transistors
- **New nodes and technology advancements are creating downward pressure on yield**
 - Yield drop with each node transition
 - Transitions to more complex digital coms (PAM4) decrease yield
 - Larger die for HPC and GPU applications are lowering wafer yield
- **As yields decrease and as device power increases Probe Card capability and CCC must increase**



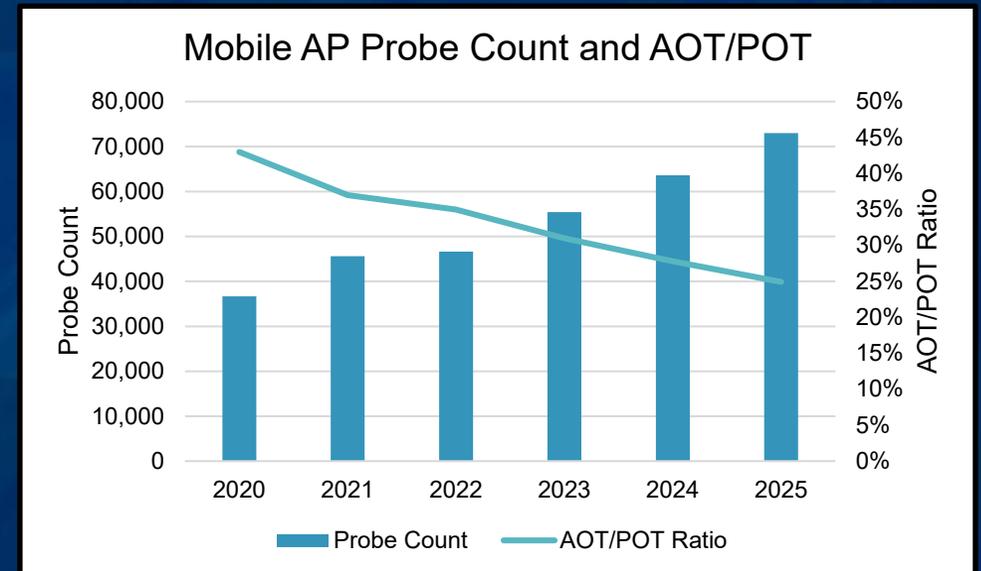
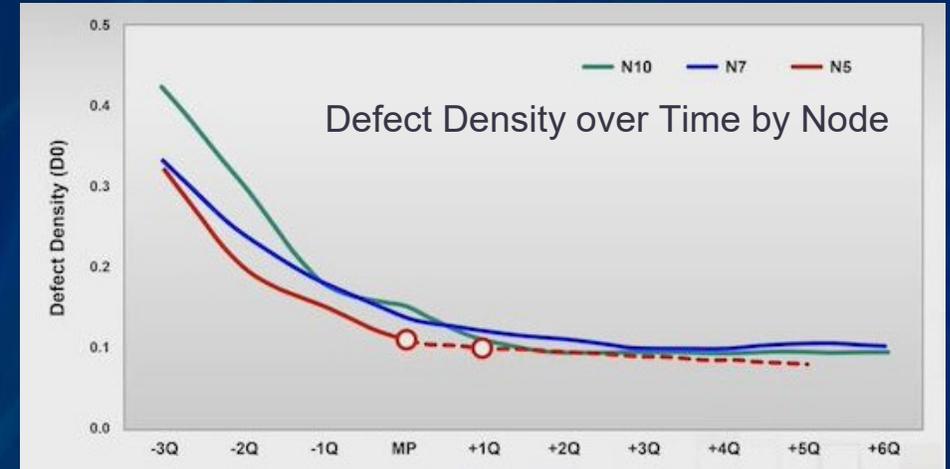
<https://www.techspot.com/article/2540-rise-of-power/>

CCC Terminology

- **Current Carrying Capability**
 - The amount of current that a probe or spring can withstand before burning or damage occurs
- **ISMI CCC**
 - Current applied where a 20% lower force is observed in a probe (spring)
- **MAC (Maximum Allowable Current)**
 - Current applied where a change in probe force or planarity is first observed
- **ECCC (Effective Current Carrying Capability)**
 - An averaging of total current that a group of probes can withstand before burning occurs

Why Does CCC Matter?

- **Probe Current Carrying Capability prevents probe burning when something goes wrong during wafer testing**
 - Shorts in the DUT
 - Unstable contact between the DUT and Probe card
- **High CCC Probes improves uptime and MTBF as the probe card becomes more robust and resistant to probe burning**



Methods for Improving CCC

**Hybrid
Probes**

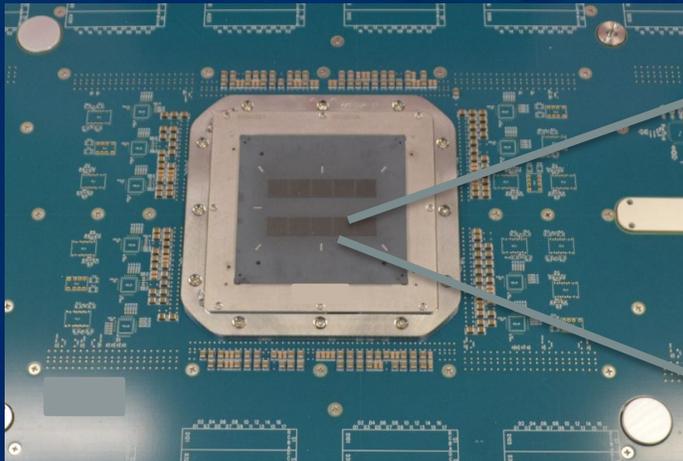
**Next
Generation
Probes**

**Metallized
Guide Plates**

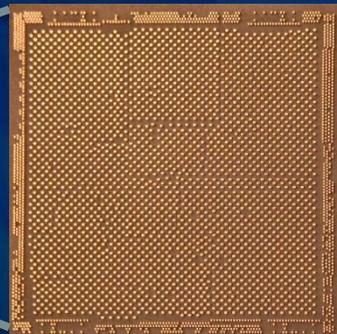
Hybrid Architecture

- **SOCs have PWR/GND in the middle of the Device and I/O in the periphery of the Device**
 - PWR/GND typically at $\geq 150\mu\text{m}$ pitch
 - Can use wider, high CCC probes
 - I/O typically at $\leq 90\mu\text{m}$ pitch
 - Can use smaller, lower CCC probes
- **By combining probe types in the Probe Card the Effective CCC is increased**

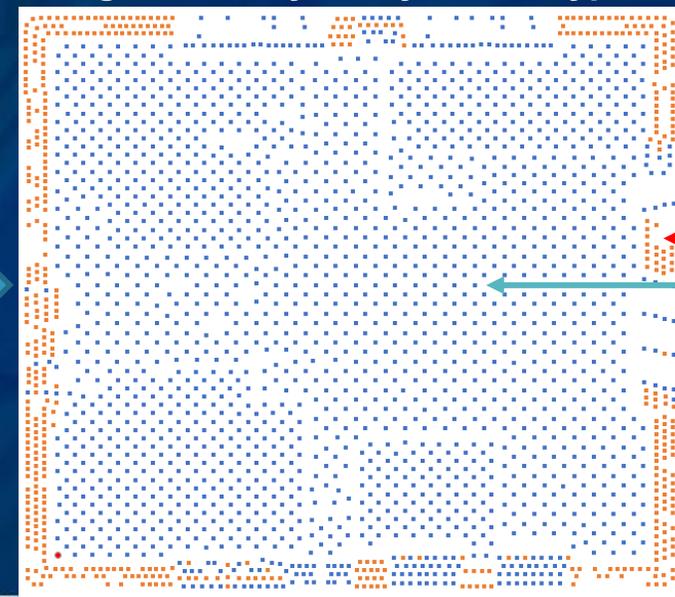
Hybrid Spring Head Probe Card – V93K DD



DUT Zoomed In



Single DUT Layout by Probe Type



Tighter Pitch Probes
with lower CCC

Wider Pitch Probes
with Higher CCC

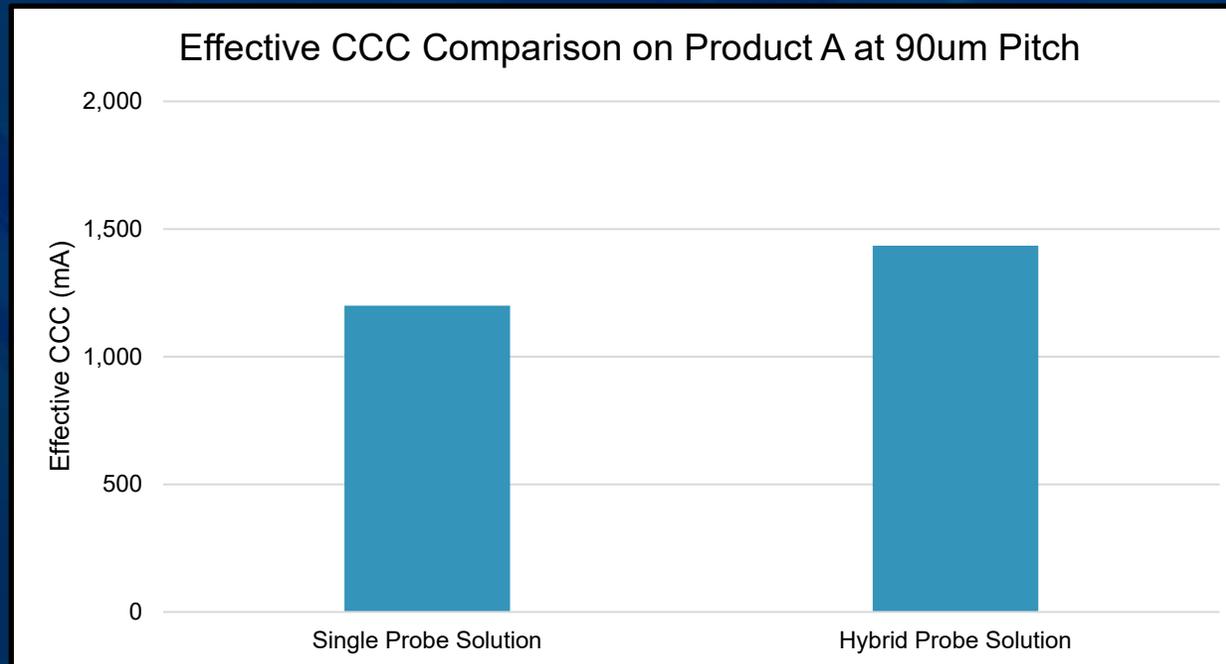
Hybrid Increasing Available CCC

- **FFI Hybrid probe technology increases probe card available CCC**
 - combining tight pitch low CCC probes and wide pitch High CCC probes in the same design
- **Product A as a test case**
 - Min Pitch = 90um
 - Requires MF100F for 90um pitch with CCC of 1,200 mA
 - If hybrid is used available CCC can be improved by 20% to 1,435 mA when using MF130/MF100

Product A x8 Hybrid Available CCC Example		
Hybrid Probe Type	MF100F	MF130F
CCC (mA)	1,200	1,500
Probe Count	4,216	15,248
Total CCC (mA)	5,059,200	22,872,000
Total Probe Card Available CCC (mA)	1,435	
% Improvement over Single Probe (MF100)	20%	

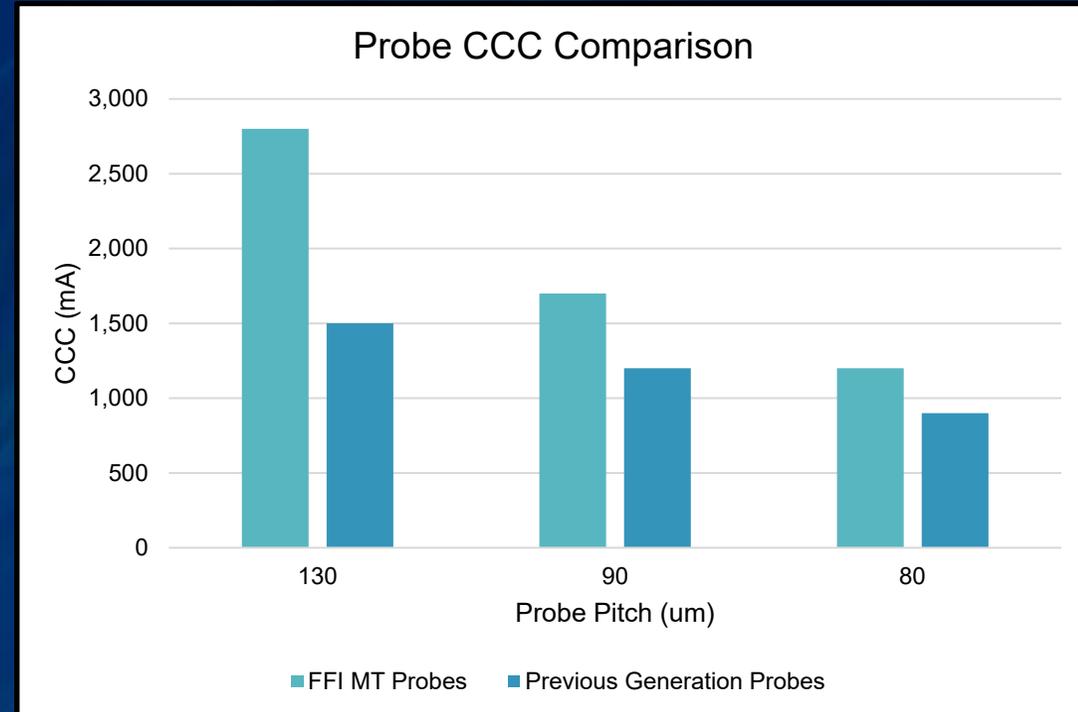
Maximizing Effective CCC

- Hybrid probes provide 20% higher effective CCC relative to single probe solutions



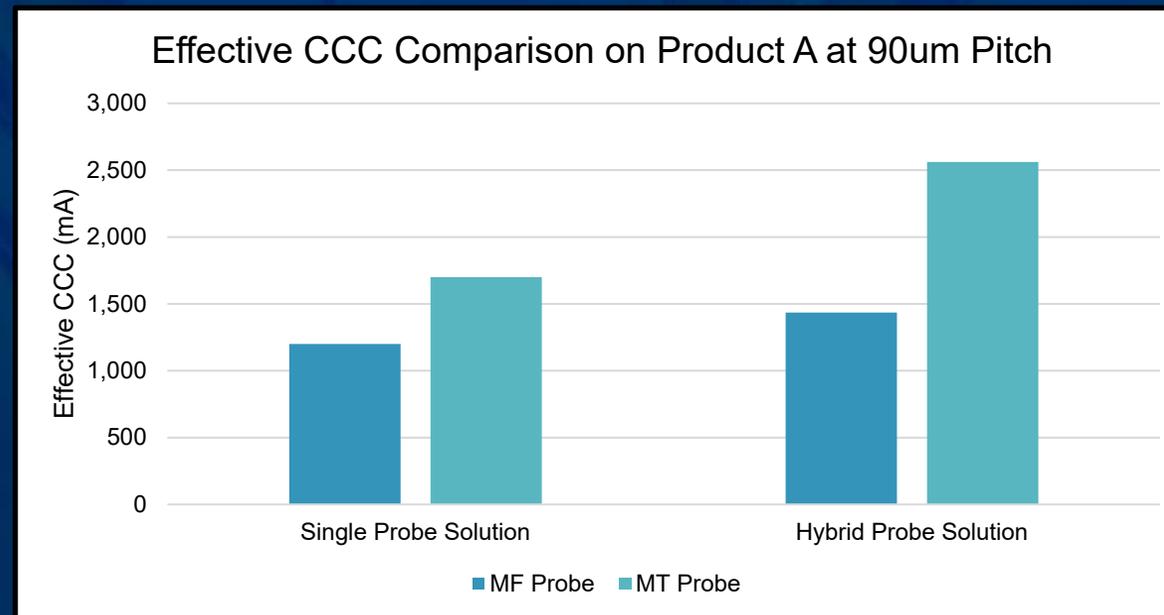
FormFactor MT Probe

- MT next generation probes provide **>50% improved CCC** over current gen. MEMS probes
- **Higher speed** performance with shorter probe length.
- **Hybrid compatible** MT probe family to further enhance CCC and high-speed capability.
- **Metallized Guide Plate** can further increase effective CCC to **>3A**

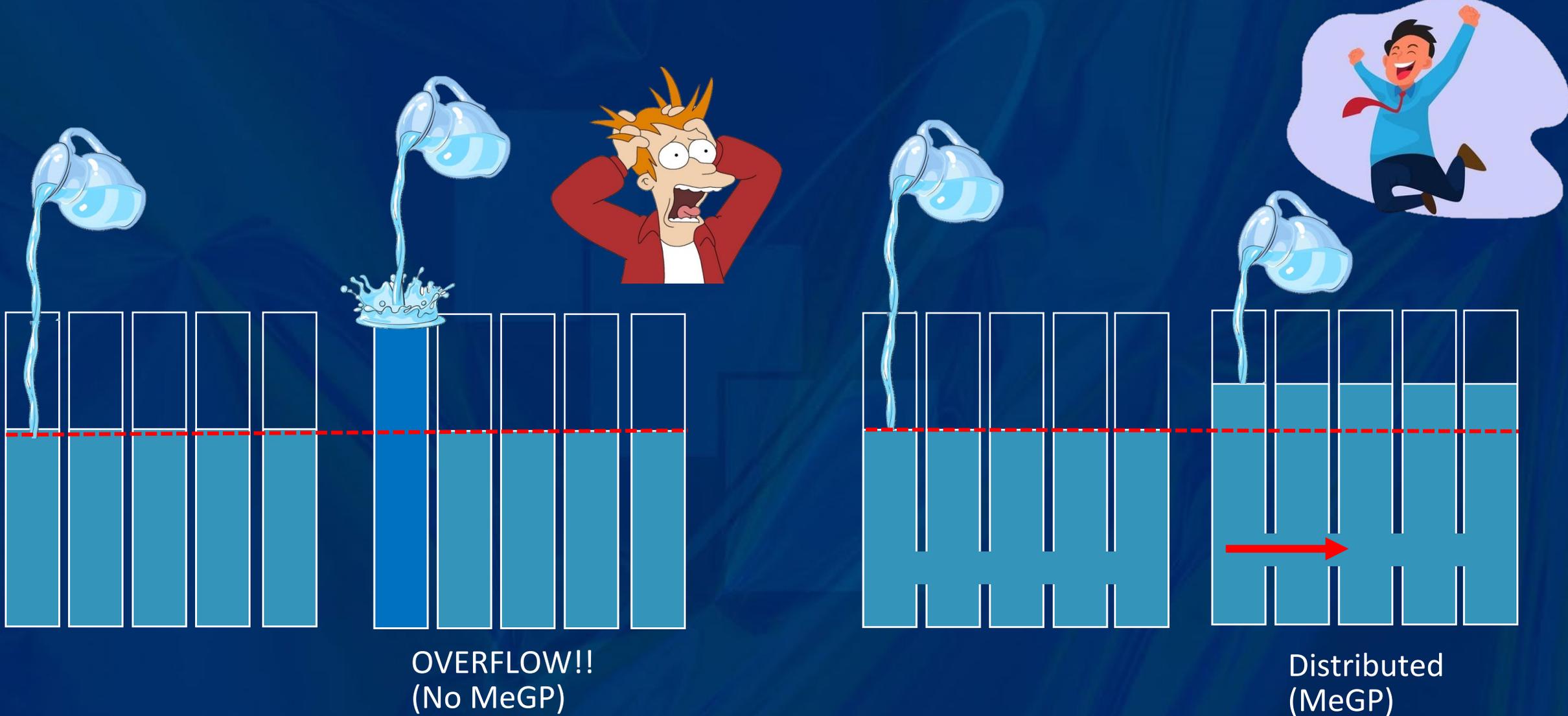


Maximizing Effective CCC

- Hybrid probes provide 20% higher effective CCC relative to single probe solutions
- MT Probes provide 42% higher CCC relative to last generation probes
 - 78% improvement when combined with Hybrid



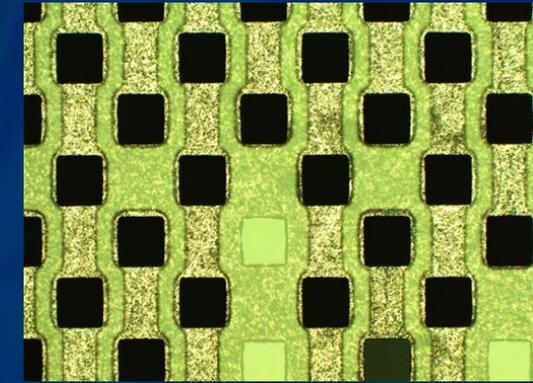
What is Metallized Guide Plate? (Analogy)



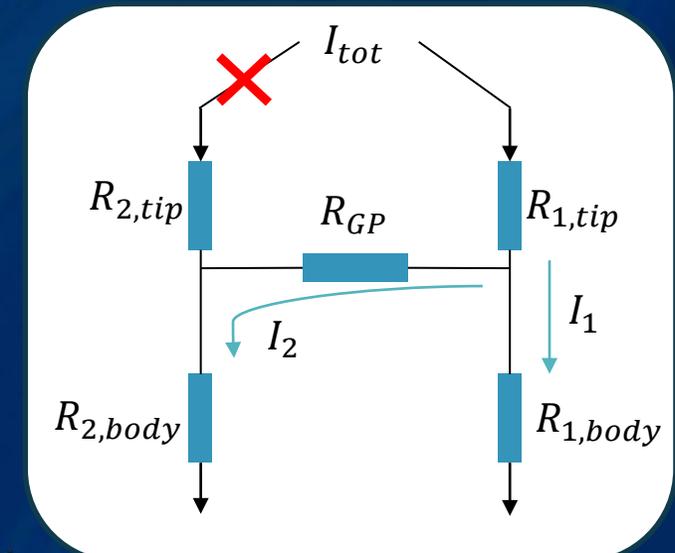
What is Metallized Guide Plate?

- Metallized Guide Plates (MeGP) connect VDD and GND nets together through metal patterns on the Guide Plate
 - Provides alternative current path when overcurrent events occur
 - Enables Improved Contact with the DUT through alternative current paths

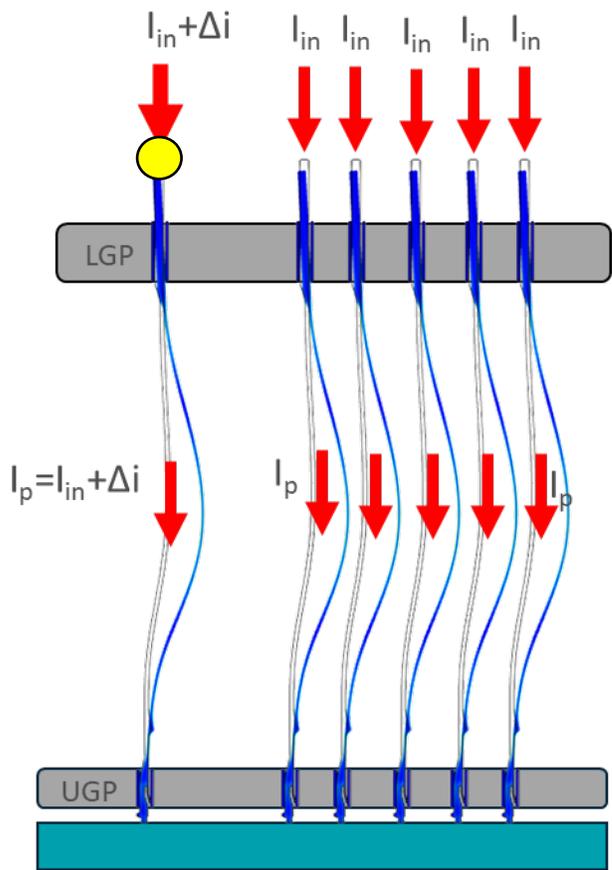
Metallization High Magnification



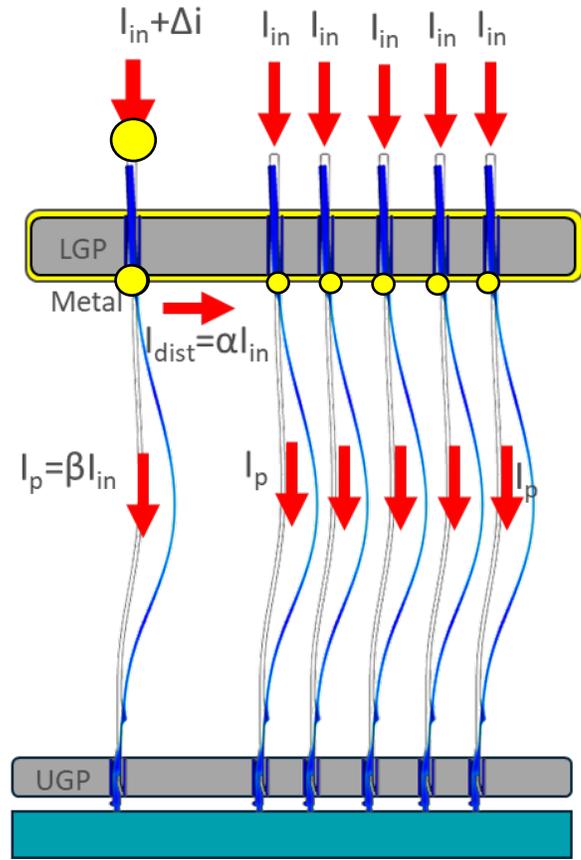
Metallization 2-Probe Circuit



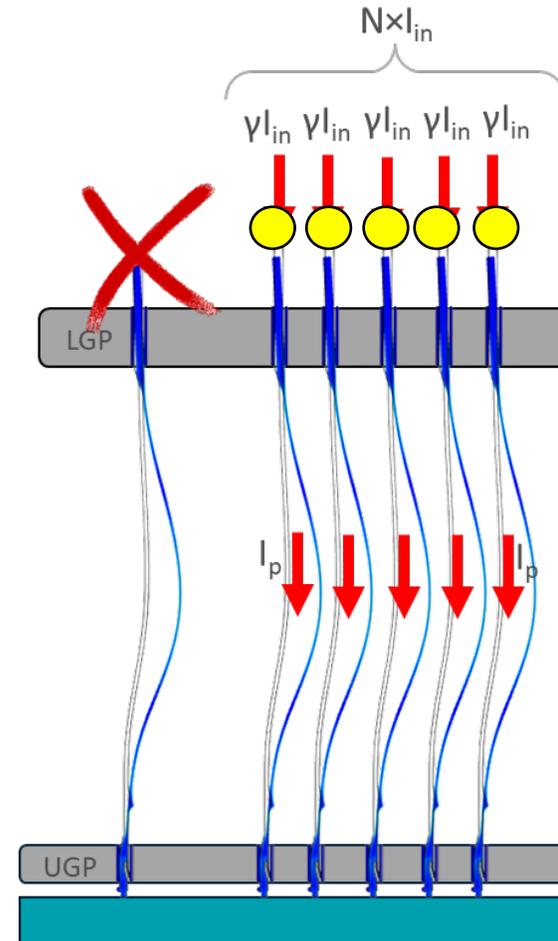
Examples of how MeGP can help



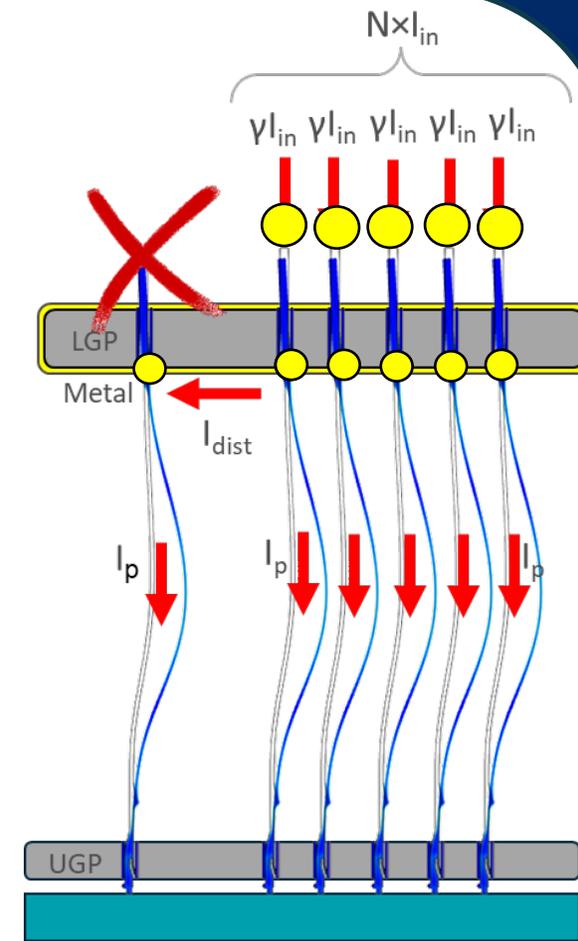
No MeGP



Current Spikes are re-distributed in MeGP case

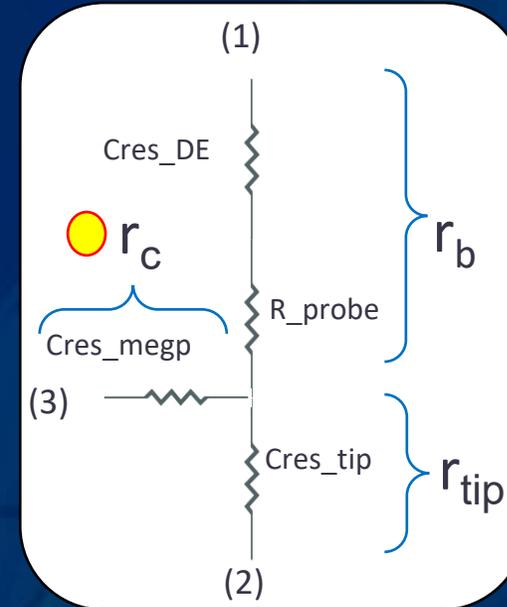
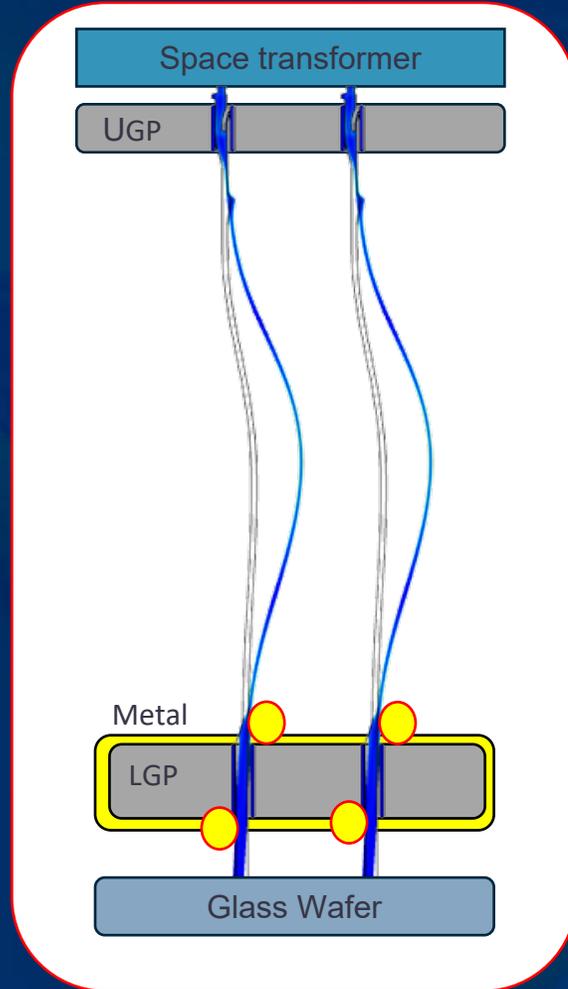


No MeGP



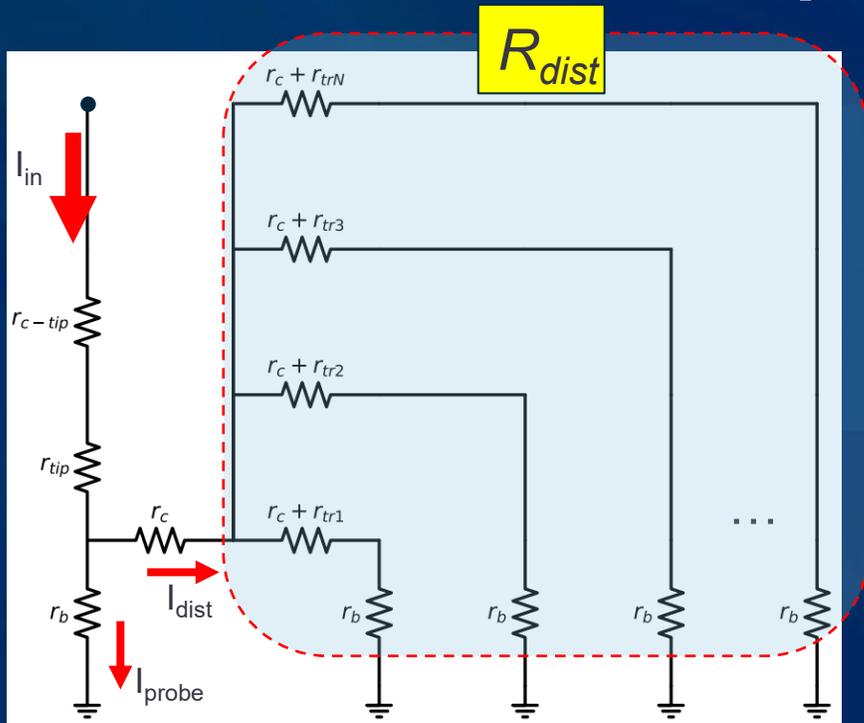
Poor contact or disconnect

MeGP Technical Terminology



- r_b : Probe body + DE Cres
- r_c : Tip-MeGP Contact resistance
- r_{tr} : Trace resistance

Generalized MeGP Effective CCC model (building block)

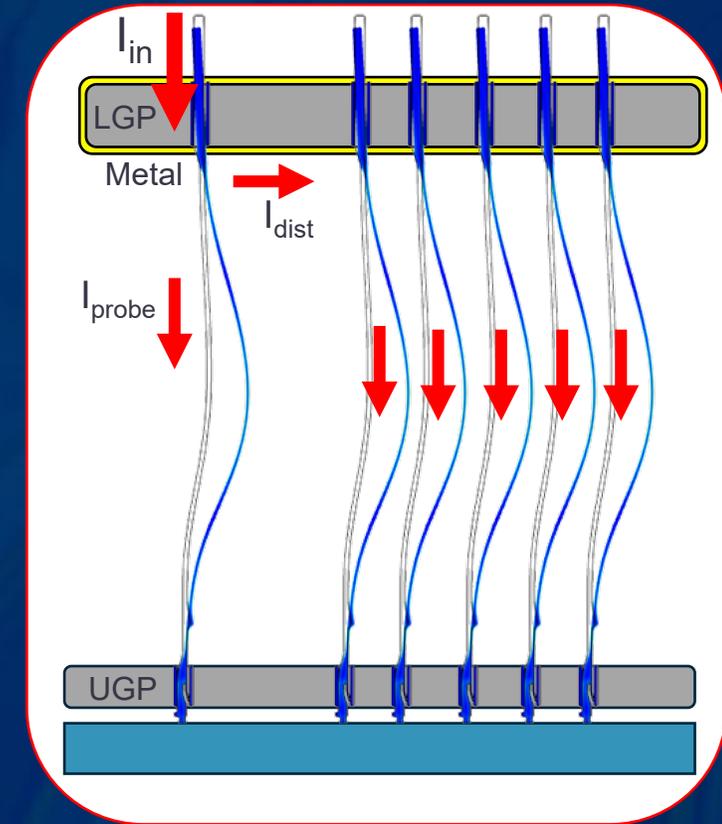


$$R_{dist} = \left(\sum_{n=1}^N \frac{1}{r_c + r_{tr(n)} + r_b} \right)^{-1}$$

Effective CCC

$$ECCC = I_{probe} \left(1 + \underbrace{\frac{r_b}{r_c + R_{dist}}}_{\text{amplification factor}} \right)$$

- r_b : Probe body + DE Cres
- r_c : Tip-MeGP Contact resistance
- r_{tr} : Trace resistance
- N : Number of probes
- R_{dist} : resistance of distributed network



Effect of trace resistance and number of probes

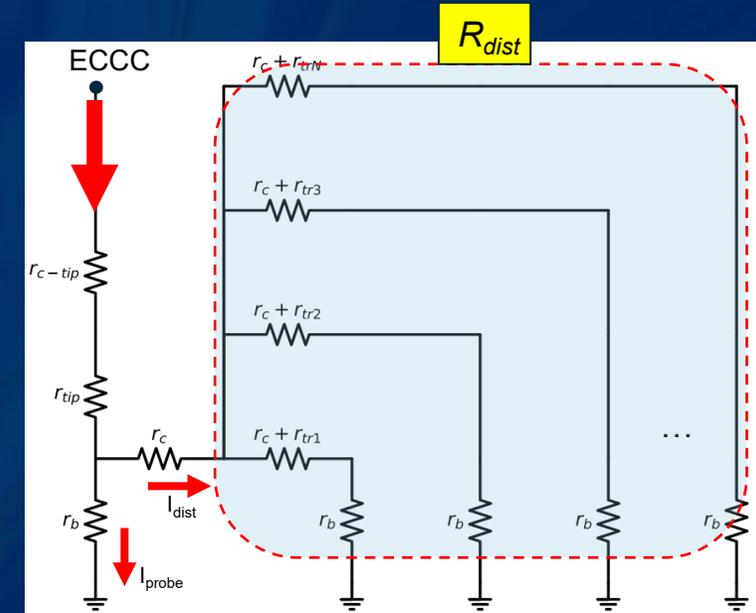
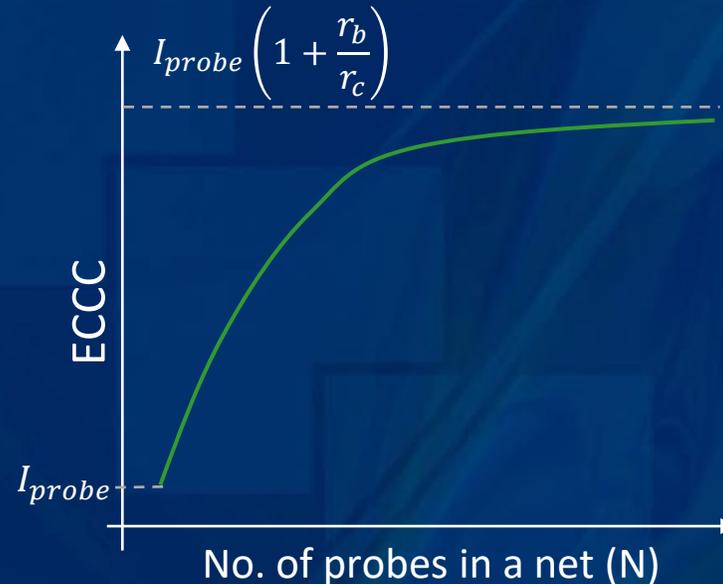
(1) If $r_{tr} \ll r_c + r_b$, the CCC will be layout independent, and the general equation reduces to:

$$ECCC_1 = I_{probe} \left(1 + \frac{r_b}{r_c + \frac{r_c + r_b}{N}} \right)$$

(2) For large gang numbers, N, the equation reduces to:

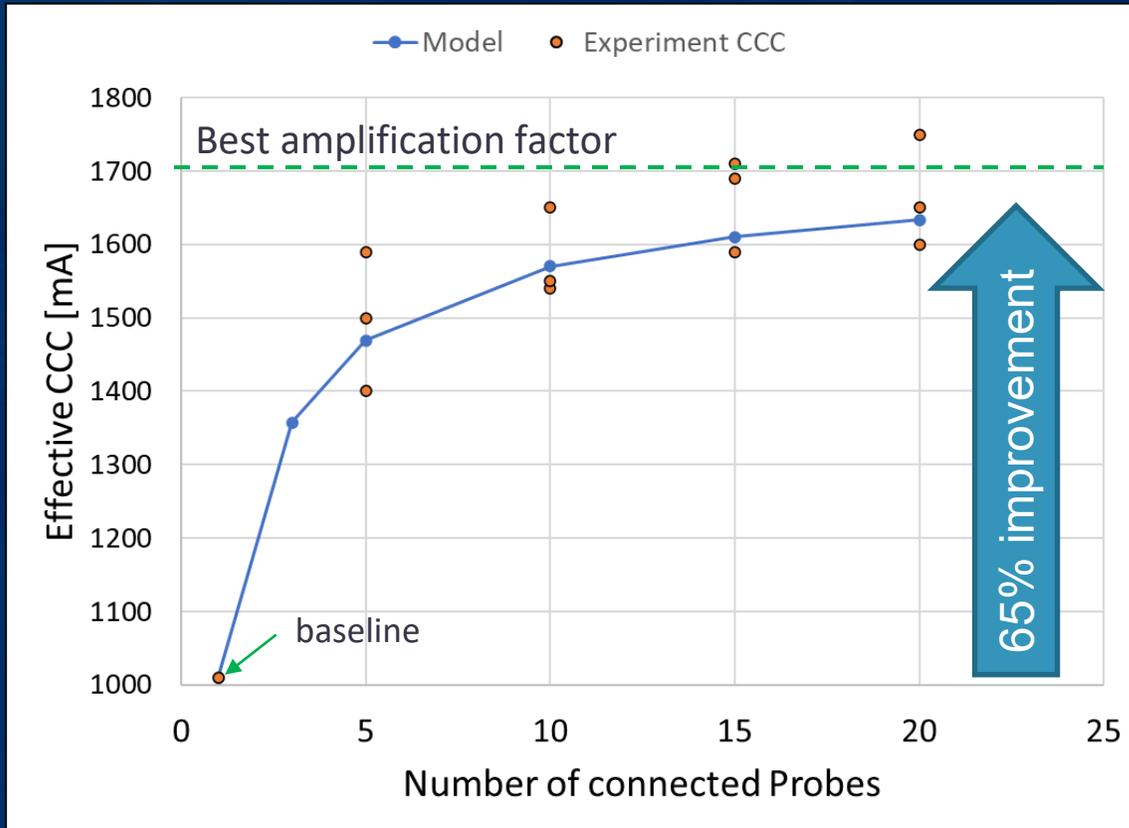
$$ECCC_2 = I_{probe} \left(1 + \frac{r_b}{r_c} \right)$$

$1 + \frac{r_b}{r_c}$ is the best CCC amplification factor one can get.



rb: Probe body + DE Cres
 rc : Tip-MeGP Contact resistance
 rtr: Trace resistance
 N: Number of probes

Validation using measured CCC and True MeGP CRES data

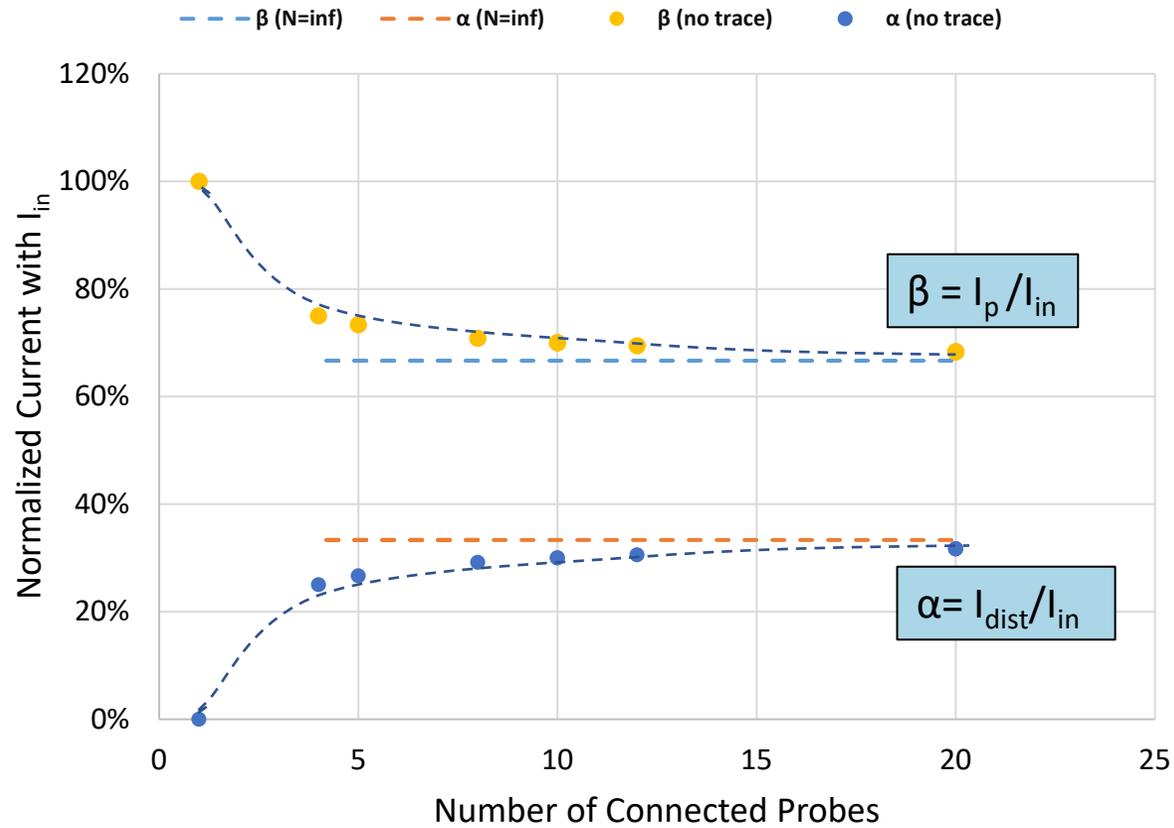


Effective CCC

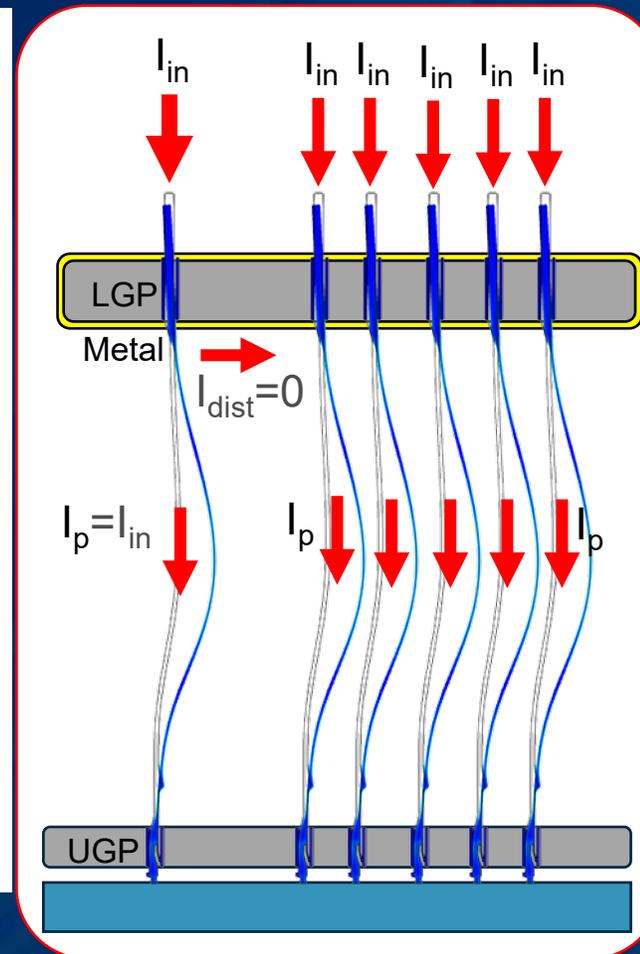
$$ECCC = I_{probe} \left(1 + \underbrace{\frac{r_b}{r_c + R_{dist}}}_{\text{amplification factor}} \right)$$

- ⑩ Excellent agreement between model and experiment was achieved.
- ⑩ ECCC showed a 65% average improvement for 20 connected probes.

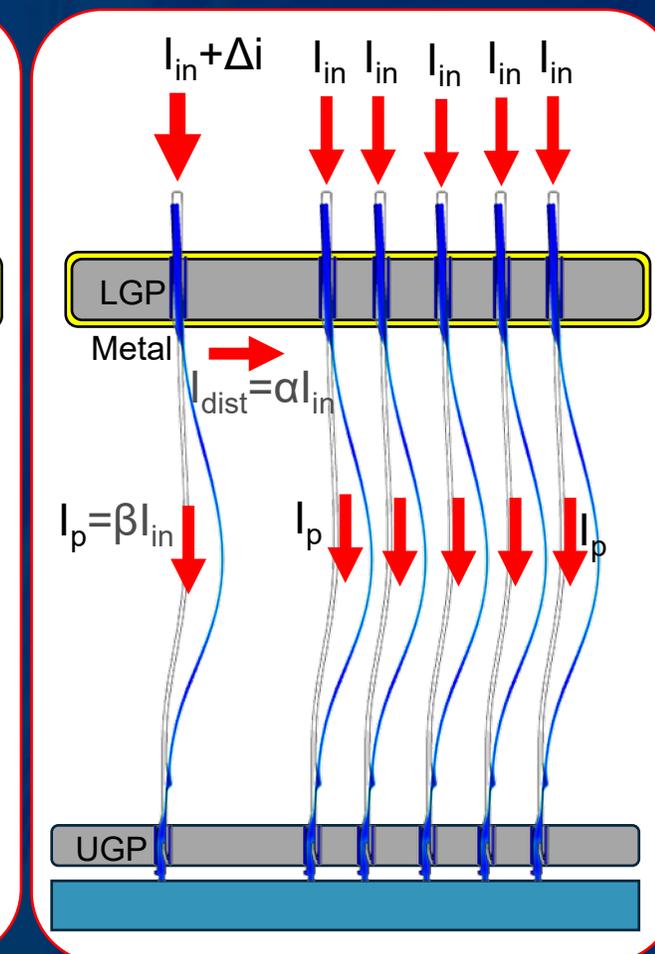
Model Extension to real cases – Current Spike events



Ideal case with no current variation

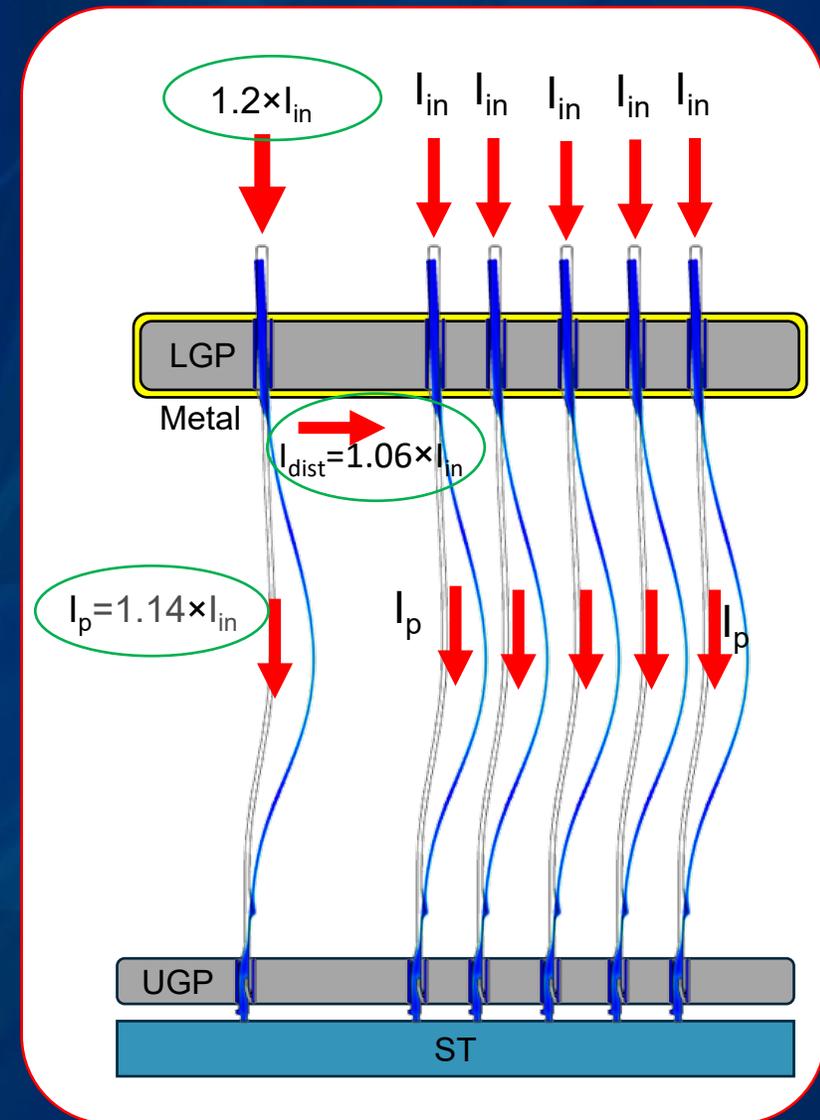


Current spike event



Numerical Example

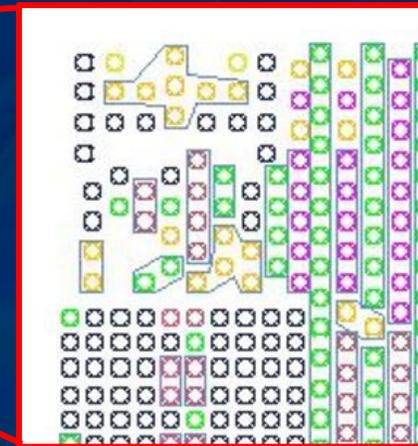
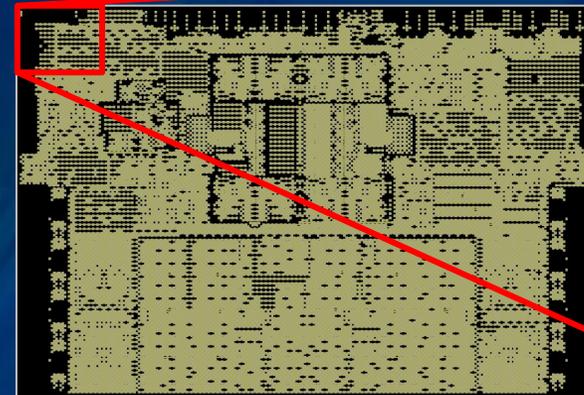
- For a 20-ganged probes with negligible trace resistance, $\alpha = 32\%$ and $\beta = 68\%$.
- A 20% increase in nominal current (I_{in}), translates to 6.4% increase in I_{dist} and 13.6% in I_{probe} .



MeGP Design Challenges

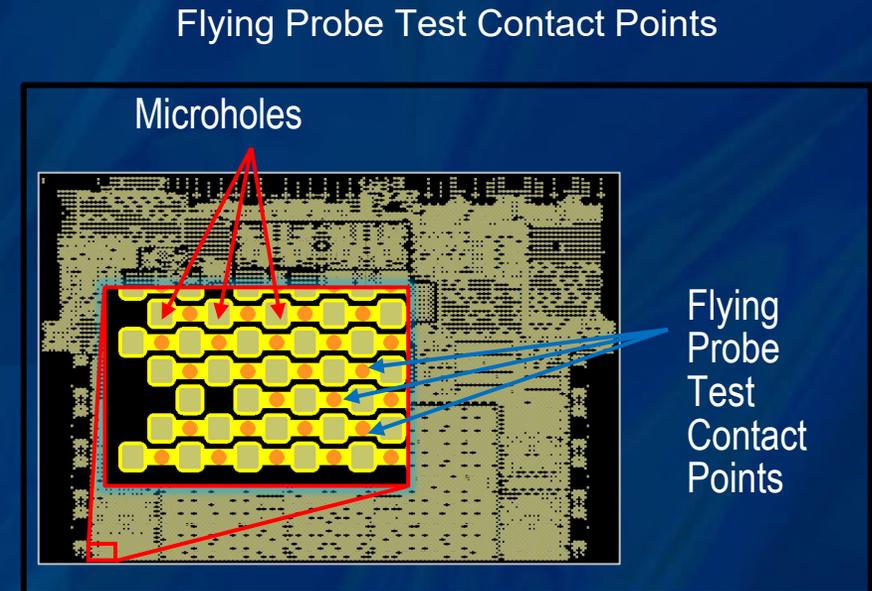
- **Challenge: Design of the MeGP is difficult due to the number of nets and probes involved.**
 - A design error could be fatal in the yield of the MeGP leading to shorts from VDD to GND
 - Design complexity could significantly
- **Solution: Automated Design and DFM rule implementation**
 - Eliminates mistakes from manual design
 - Decreases design cycle time to a few hours

Design Automation Improves Design Cycle Time and Reduces Errors



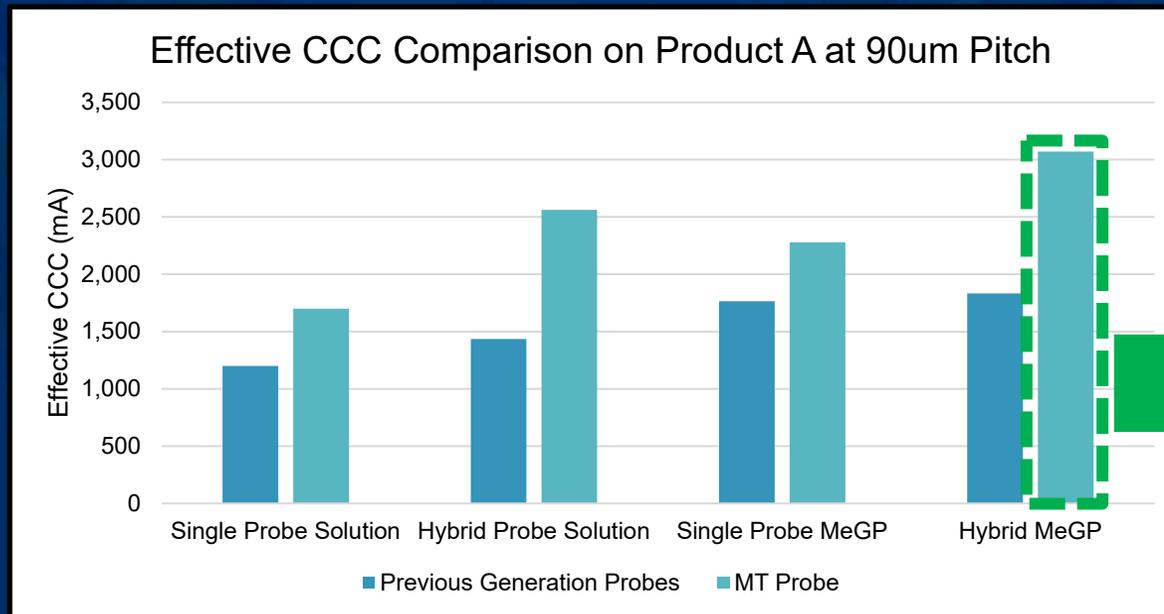
MeGP Verification Challenges

- **Challenge: MeGP needs to be verified for shorts before stitching the probes and completing assembly of the Probe Card**
 - POR process flow verifies electrical continuity with PRVX
 - If short is found the Probe Head would need to be disassembled and fixed
 - Long Cycle times at the last step of the manufacturing process
- **Solution: Implementation of Flying Probe Test after MeGP Plating**
 - Allows rework of GPs if needed
 - Ensures high quality through manufacturing process



Maximizing Effective CCC

- MeGP Improves Effective CCC by 65% depending on the probe architecture
- FFI has achieved the first >3A CCC Probe card at 90um pitch using Next generation MT Probes, Hybrid probes, and Metallized Guide Plate
 - Short Cycle Time and Excellent quality guaranteed through Design Automation and Outgoing Flying Probe Test



MT Hybrid with MeGP provides Best Effective CCC >3A

Thank You!!